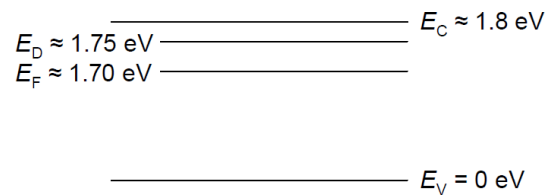


# SOLUTION 3

## Exercise 1: Occupation function of a donor state

- a) In the figure below you can see the band diagram of  $n$ -type doped amorphous silicon with approximative values for the requested energy levels. The position of these levels — namely  $E_D$  and  $E_F$  — depend on various parameters such as the dopant concentration and shall only give an idea of the order of magnitude.



The choice of  $E_V = 0$  as reference is absolutely arbitrary.

- b) With only one energy level between the valence and the conduction band at  $E_D$  close to  $E_F$ , an electron will occupy most likely that level. As a fermion, the electron can occupy this level in two different spin configurations (spin up and down) with the same probability, we call these states  $D_{\text{up}}$  and  $D_{\text{down}}$ . The next probable state is with an electron at the conduction band edge, we call it C.

When the system is in thermal equilibrium (i.e. the probability that a hypothetical state at  $E_F$  is occupied is exactly 50 %), we consider the energy of the system to be 0. Therefore, the system with an electron at  $E_{D_{\text{up}}} = E_{D_{\text{down}}}$  has the energy  $E_D - E_F$ , the system with an electron at  $E_C$  has the energy  $E_C - E_F$ .

- c) In a system with  $j$  states that have the energy  $E_j$ , the probability that the system is in state  $i$  is given by

$$p_i = \frac{e^{-\frac{E_i}{k_B T}}}{\sum_j e^{-\frac{E_j}{k_B T}}}. \quad (1)$$

For the states  $D_{\text{up}}$  and  $D_{\text{down}}$ , this is

$$p_{D_{\text{up}}} = p_{D_{\text{down}}} = \frac{e^{-\frac{E_D - E_F}{k_B T}}}{2 \cdot e^{-\frac{E_D - E_F}{k_B T}} + e^{-\frac{E_C - E_F}{k_B T}}}. \quad (2)$$

The probability that the system is in the state D — be it spin up or down — is therefore

$$p_D = 2 \cdot p_{D_{\text{down}}} = \frac{2 \cdot e^{-\frac{E_D - E_F}{k_B T}}}{2 \cdot e^{-\frac{E_D - E_F}{k_B T}} + e^{-\frac{E_C - E_F}{k_B T}}} \quad (3)$$

$$= \frac{1}{1 + \frac{1}{2} \cdot e^{-\frac{E_C - E_F}{k_B T} + \frac{E_D - E_F}{k_B T}}} \quad (4)$$

$$= \frac{1}{1 + \frac{1}{2} \cdot e^{-\frac{E_C - E_D}{k_B T}}} \quad (5)$$

$$= 93\% \quad \text{with} \quad k_B T = 0.026 \text{ eV} \quad \text{at room temperature.} \quad (6)$$

The probability that the system is in the state C is

$$p_C = 1 - p_D = 7\% \quad \text{or} \quad (7)$$

$$= \frac{e^{-\frac{E_C - E_F}{k_B T}}}{2 \cdot e^{-\frac{E_D - E_F}{k_B T}} + e^{-\frac{E_C - E_F}{k_B T}}} \quad (8)$$

$$= \frac{1}{2 \cdot e^{-\frac{E_D - E_F}{k_B T} + \frac{E_C - E_F}{k_B T}} + 1} \quad (9)$$

$$= \frac{1}{2 \cdot e^{-\frac{E_D - E_C}{k_B T}} + 1} \quad (10)$$

$$= 7\% \quad (11)$$

d) Under the assumptions that

- the phosphorus concentration is  $c_P = 10^{-6}$  which corresponds to  $N_P = c_P \cdot N_{\text{Si}} = 5 \times 10^{16} \text{ cm}^{-3}$ ,
- the doping efficiency is 100% (i.e. all dopants substitute a silicon atom in the «lattice» and can contribute an electron to the conduction band),
- the formula derived above is still valid for a multi-state system, and
- thermal excitation from other energy levels than the dopant level (e.g. from the valence band) into the conduction band is negligible.

the electron density in the conduction band is  $N_e = p_C \cdot N_P = 4.3 \times 10^{15} \text{ cm}^{-3}$ .

e) The derived equation is nothing else than the occupation function of energy states introduced by impurities or dopants. The Fermi-Dirac distribution

$$F_{F-D}(E) = \frac{1}{1 + e^{\frac{E - E_F}{k_B T}}} \quad (12)$$

can be derived exactly the same way but for states that can be occupied only once. To do so, we consider a state at energy  $E$ , either filled (1) or empty (0), in exchange with a “reservoir” at  $E_F$ :

$$F_{F-D}(E) = p_E = \frac{e^{-\frac{E - E_F}{k_B T}}}{e^{-\frac{0 \cdot (E - E_F)}{k_B T}} + e^{-\frac{1 \cdot (E - E_F)}{k_B T}}} = \frac{1}{1 + e^{\frac{E - E_F}{k_B T}}} \quad (13)$$

**Exercise 2: Meyer-Neldel behaviour in the conductivity of a-Si:H**

We assume that  $T \neq 0$ , i.e.  $\alpha \neq 1$ .

a) We compute

$$\begin{aligned} L &= \frac{\mu_{00}E}{\omega^\alpha} \int_0^{t_L} t^{-\alpha} dt \\ &= \frac{\mu_{00}E}{\omega^\alpha} \frac{t_L^{1-\alpha}}{1-\alpha}. \end{aligned}$$

Thus we get:

$$t_L^{1-\alpha} = \frac{L\omega^\alpha (1-\alpha)}{\mu_{00}E} \quad (14)$$

and

$$t_L = \left( \frac{L\omega^\alpha (1-\alpha)}{\mu_{00}E} \right)^{\frac{1}{1-\alpha}}. \quad (15)$$

b) In the following, we'll use the fact that  $\omega^\alpha = \frac{\omega}{\omega^{1-\alpha}}$ , and hence (with (14))

$$(\omega t_L)^{1-\alpha} = \frac{L\omega (1-\alpha)}{\mu_{00}E}.$$

Thus,

$$\omega t_L = \left( \frac{L\omega (1-\alpha)}{\mu_{00}E} \right)^{\frac{1}{1-\alpha}}. \quad (16)$$

We now calculate

$$\begin{aligned} \mu(t_L) &= \mu_{00}(\omega t_L)^{-\alpha} \stackrel{(16)}{=} \mu_{00} \left( \frac{L\omega (1-\alpha)}{\mu_{00}E} \right)^{-\frac{\alpha}{1-\alpha}} \\ &= \mu_{00} \left( \frac{L\omega (1-\alpha)}{\mu_{00}E} \right)^{\left( \frac{1-\alpha}{1-\alpha} - \frac{1}{1-\alpha} \right)} \\ &= \mu_{00} \left( \frac{L\omega (1-\alpha)}{\mu_{00}E} \right) \cdot \underbrace{\left( \frac{L\omega (1-\alpha)}{\mu_{00}E} \right)^{-\frac{1}{1-\alpha}}}_{(\omega t_L)^{-1}} \\ &= \underbrace{\frac{L\omega(1-\alpha)}{\mu_0}}_E \frac{1}{\omega t_L}. \end{aligned}$$

c) Using (16) and the definition of  $\mu_0$ , we start with the previous result and calculate:

$$\begin{aligned}
 \mu(t_L) &= \mu_0 \frac{1}{\omega t_L} \\
 &= \mu_0 \left( \frac{\mu_0}{\mu_{00}} \right)^{-\frac{1}{1-\alpha}} \\
 &= \mu_0 \left( \frac{\mu_0}{\mu_{00}} \right)^{-\frac{T_0}{T}} \\
 &= \mu_0 \exp \left[ -\frac{T_0}{T} \ln \left( \frac{\mu_0}{\mu_{00}} \right) \right] \\
 &= \mu_0 \exp \left[ -\frac{kT_0 \ln \left( \frac{\mu_0}{\mu_{00}} \right)}{kT} \right] \\
 &\stackrel{\text{def}}{=} \mu_0 \exp \left( -\frac{E_{\text{mob}}}{kT} \right) \\
 &= \mu(T).
 \end{aligned}$$